

## Refine Search

### Search Results -

Terms	Documents
L3 not L2	101

Database:

US Pre-Grant Publication Full-Text Database  
 US Patents Full-Text Database  
 US OCR Full-Text Database  
 EPO Abstracts Database  
 JPO Abstracts Database  
 Derwent World Patents Index  
 IBM Technical Disclosure Bulletins

Search:

L4

Refine Search

Recall Text

Clear

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### Search History

DATE: Sunday, January 29, 2006 , [Printable Copy](#) [Create Case](#)

<u>Set</u> <u>Name</u>	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
side by side			
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
<u>L4</u>	L3 not L2	101	<u>L4</u>
<u>L3</u>	cerium oxide and (polishing or planarizing or planarization or polished) same glass near4 (disk or disc) and (abrasive or polishing adj (particle or particulate or grit or grain) or cerium iv oxide or "ceo.sub.2" or ceo2) with (size or diameter)	151	<u>L3</u>
<u>L2</u>	L1 and (abrasive or polishing adj (particle or particulate or grit or grain) or cerium iv oxide or "ceo.sub.2" or ceo2) with (size or diameter)	62	<u>L2</u>
<u>L1</u>	(cerium iv oxide or "ceo.sub.2" or ceo2) and (polishing or planarizing or planarization or polished) same glass near4 (disk or disc)	133	<u>L1</u>

END OF SEARCH HISTORY